

Electronic Supplementary Information

A strategy to control grain boundary density and Cu⁺/Cu⁰ ratio of Cu-based catalysts for efficient electroreduction of CO₂ to C2 products

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Experimental Section

Materials: Ethanol, orthophosphoric acid (85%), sodium hydroxide (NaOH), potassium persulfate ($K_2S_2O_8$) and acetone were obtained from Sinopharm Chem. Reagent Co. Ltd. Cu film, $H_2^{18}O$, Potassium bicarbonate ($KHCO_3$) and Nafion N-117 membrane (0.180 mm thick, ≥ 0.90 meg/g exchange capacity) were purchased from Alfa Aesar China Co., Ltd. N_2 and CO_2 (99.999%) were provided by Beijing Analytical Instrument Company.

Synthetic procedures for $Cu(OH)_2$: $Cu(OH)_2$ were prepared through modified chemical immersion method.^{S1} In a typical procedure, a Cu foil (10 mm×10 mm) was mechanically polished, then electropolished in 85 wt% phosphoric acid at 2.0 V vs. Ag/AgCl for 500 s. Polished Cu foils were washed with deionized water, and immersed into a chemical bath immediately. The bath was filled with sodium hydroxide (4.0 g), potassium persulfate (1.62 g) and deionized water (40 mL). After 10 h, $Cu(OH)_2$ film was obtained, and then it was washed with deionized water.

Synthetic procedures for R-Cu-x: Firstly, the muffle furnace was preheated to 500 °C with a heating rate of 10 °C min⁻¹ and maintained at 500 °C. Then the obtained $Cu(OH)_2$ was quickly put in the muffle furnace with 500 °C by crucible tongs, and taken out quickly after calcining for several minutes. The $Cu(OH)_2/CuO$ composites were prepared. For clarity, Composites-x refers to $Cu(OH)_2/CuO$ film, and x represents the the minutes of calcination. Finally, Composites-x were electrochemically reduced at -2.0 V vs. RHE for 500 s, leading to the formation of R-Cu-x.

Materials characterizations: The microstructures of the catalysts were characterized by scanning electron microscope (SEM, HITACHI S-4800) and transmission electron microscopy (TEM, JEOL JEM-2100F) equipped with EDS. X-ray photoelectron spectroscopy (XPS) study was carried out on the Thermo Scientific ESCALab 250Xi using a 200W Al-K α radiation. In the analysis chamber, the base pressure was about 3×10^{-10} mbar. Typically, the hydrocarbon C1s line at 284.8 eV from adventitious carbon was used for energy referencing. X-Ray diffraction (XRD) analysis of the samples were performed on a Rigaku D/max-2500 X-ray diffractometer with Cu-K α radiation ($\lambda = 0.15406$ nm) and the scan speed was 5°/min. The Raman spectra of the samples were obtained at room temperature in flamesealed capillary on a FT Bruker RFS 106/S spectrometer, equipped with a 514 nm laser, in the region from 1000 to 100 cm⁻¹ with a resolution of 2 cm⁻¹.

Semi-in-situ X-ray photoelectron spectroscopy. In order to detect accurately the valence state of Cu, the XPS samples were processed in a glove box. After electrolysis, the electrode plate was soaked in acetone solution, and put into the glove box immediately. The obtained electrode plate was cut into 3 × 3 mm and glued on a support. The support could be evacuated into vacuum to prevent the samples to be oxidized by the air. The subsequent testing

processes were the same as the common XPS.

Electrochemical study: All the experiments of CO₂ reduction were carried out on the electrochemical workstation (CHI 660E, Shanghai CH Instruments Co., China). Linear sweep voltammetry (LSV) scans were conducted in a single compartment cell with a three electrodes configuration, which consisted of working electrode, a platinum gauze as counter electrode, and Ag/AgCl (saturated KCl solution) as reference electrode. Prior to experiment, the electrolyte was bubbled with N₂ or CO₂ at least 30 min to form N₂ or CO₂ saturated solution. LSV measurement in gas-saturated electrolytes was conducted in the potential range of 0 V to -1.2 V versus RHE at a desired 20 mV s⁻¹ sweep rate. All potentials cited in this work were referenced to the RHE. The potentials were converted to RHE using the formulas $E(\text{vs RHE}) = E(\text{vs Ag/AgCl}) + 0.197 \text{ V} + 0.0591 \times \text{pH}$.

The electrolysis experiments were conducted at 25 °C in a H-type cell^{S2} with a working cathode, a counter anode (platinum gauze), and a reference electrode (Ag/AgCl with saturated KCl). In the experiment, Nafion-117 membrane was used as proton exchange membrane to separate the cathode and anode compartments. KHCO₃ aqueous solution (0.1 M) were used as electrolyte. In each experiment, the amount of electrolyte was 30 mL. Before the electrolysis experiment, the catholyte was bubbled with CO₂ for 30 min under stirring and the electrolysis was carried out under a steady stream of CO₂ (20 sccm).

Product analysis. The gaseous product of electrochemical experiments was collected using a gas bag and analyzed by gas chromatography (GC, HP 4890D), which was equipped with TCD detectors using argon as the carrier gas. The liquid product was analyzed by ¹H NMR (Bruker Avance III 400 HD spectrometer) in deuteroxide with phenol as an internal standard.

Calculations of Faradaic efficiencies of gasous and liquid products.

liquid products:

After electrolysis, a certain amount of phenol solution was added to the electrolyte as the internal standard. Because the concentration of phenol was known, the moles of liquids products can be calculated from integral areas and calibration curves.

The Faradaic efficiency of liquid product is:

$$FE = \frac{\text{moles of product}}{Q / nF} \times 100\%$$

(Q: electric quantity; F: Avogadro constant; n: transfer electron number)

Gasous products:

From the GC peak areas and calibration curves for the TCD detector, we can obtain the V % of gasous products .

Since the flow rate of the CO₂ was constant, the moles of gaseous products can be calculated. The Faradaic efficiency of gaseous product is:

$$FE = \frac{\text{moles of product}}{Q / nF} \times 100\%$$

(Q: electric quantity; F: Avogadro constant; n: transfer electron number)

Electrochemical impedance spectroscopy (EIS) study: The EIS measurement was carried out in KHCO₃ aqueous solution (0.1 M) at an open circuit potential (OCP) with an amplitude of 5 mV of 10⁻² to 10⁵ Hz.

Double-layer capacitance (C_{dl}) measurements: The electrochemical active surface area is proportional to C_{dl} value. C_{dl} was determined by measuring the capacitive current associated with double-layer charging from the scan-rate dependence of cyclic voltammogram (CV). The CV ranged from -0.6 V to -0.7 V vs. Ag/AgCl. The C_{dl} was estimated by plotting Δ*j* (*j_a*-*j_c*) at -0.65 V vs Ag/AgCl against the scan rates, in which *j_a* and *j_c* were the anodic and cathodic current density, respectively. The scan rates were 20, 30, 40, 50 and 60 mV s⁻¹.

The ECSA of the working electrodes could be calculated according to the following equation: ECSA = R_fS, where S was the real surface area of the working electrode and R_f was the roughness factor of the working electrode. Notably, S was generally equal to the geometric area of working electrode (in this work, S = 1 cm²). The roughness factor (R_f) can be calculated by the relation R_f = C_{dl}/a. The roughness factor of R-Cu(OH)₂ was defined to be 1, then the normalized current density can be calculated according to roughness factor of different catalysts.

Measurement of grain boundary (GB) surface densities^{S3}:

The method described below was chosen to provide an accurate measurement of the relative GB surface density. We chose ~30 nanoparticles from high resolution TEM images for each of R-Cu-x sample (as-deposited R-Cu(OH)₂, R-Cu-2, R-Cu-5, R-Cu-10 and R-Cu-20). For each of these NP images, the length of the GBs (if present) and the particle area were measured.

L_{*i*} = GB length in TEM image for particle *i*

A_{*i*} = particle area in TEM image for particle *i*

L_{*i*} was determined by measuring the length of a line traced over the GB image. Most particles had GBs, so the GBs were readily identified. To measure A_{*i*}, each particle image was approximated either as a circle, a rod with semi-circular caps, or a combination of these shapes (see below). The image was fit to two shapes, one slightly smaller than the image and one slightly larger. A_{*i*} was taken to be the average of the areas of these two fits. This method of measuring the particle area in the TEM image was chosen because the values could readily be converted into 3D particle surface areas. The measured values L_{*i*} and A_{*i*} were converted to the 3D GB surface lengths and the 3D

particle surface areas using conversion factors derived from the assumption that the particles have round morphologies:

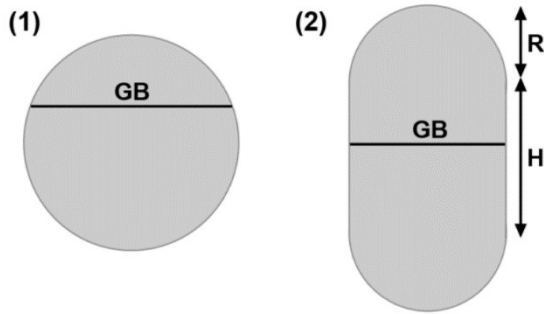
C_L = conversion factor from measured GB length L_i to 3D GB surface length;

C_A = conversion factor from measured particle area A_i to 3D particle surface area.

The 3D GB surface length was approximated as the circumference of a circle with diameter L_i :

3D GB surface length $= \pi L_i$, so conversion factor $C_L = \pi$

The value for C_A depends on the particle shape as illustrated in the following examples:



(1) Spherical shape, with radius R and measured GB length L

3D GB surface length $= \pi L$

3D particle surface area $= 4\pi R^2$, so conversion factor $C_A = 4$ for this model.

(2) Cylindrical shape with length H , hemispherical ends of radius R , and GB length L

3D GB surface length $= \pi L$

3D particle surface area $= 4\pi R^2 + 2\pi RH$, so $C_A = \frac{4\pi R^2 + 2\pi RH}{\pi R^2 + 2RH} = 4 - \frac{4 - \pi}{1 + \frac{\pi R}{2H}}$ for this model.

(3) Other complicated geometries (a small fraction) could be divided into parts that fit simple models such as sphere, hemisphere, and cylinder.

Using all of the measured values for L_i and A_i for all of the NPs imaged, and the appropriate conversion factors, the

3D GB surface densities were calculated as follows:

$$\text{3D GB surface density} = \frac{\sum_{\text{All particles}} \text{GB Surface Length}}{\sum_{\text{All particles}} \text{Surface Area}} = \frac{\sum_i \pi L_i}{\sum_i C_A A_i}$$

Supplementary Figures

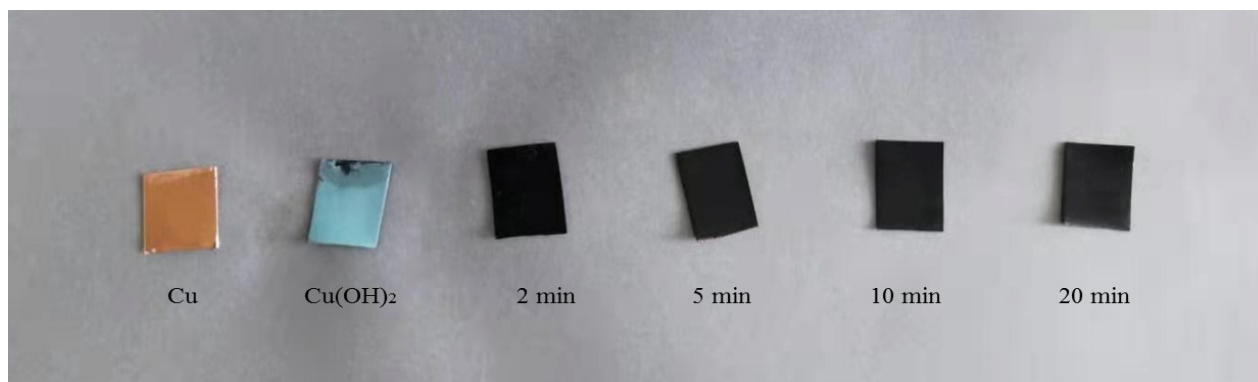


Figure S1. The optical pictures of the samples.

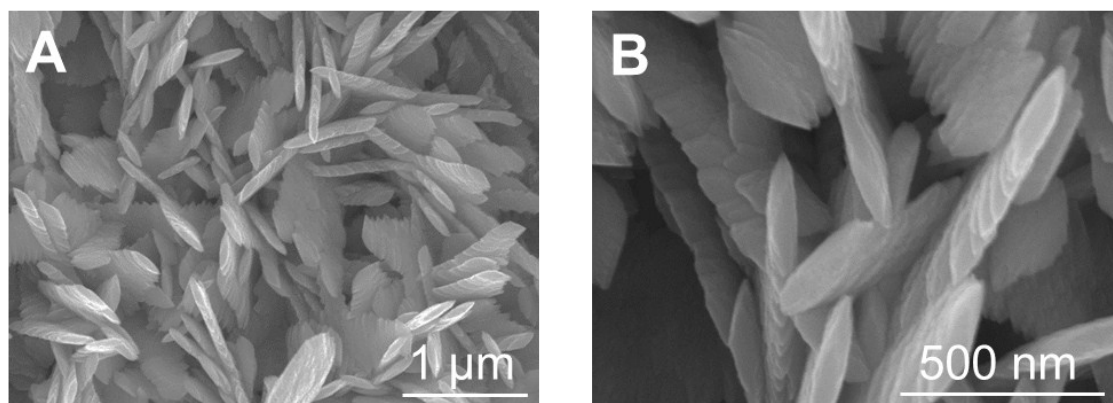


Figure S2. SEM images of Cu(OH)₂.

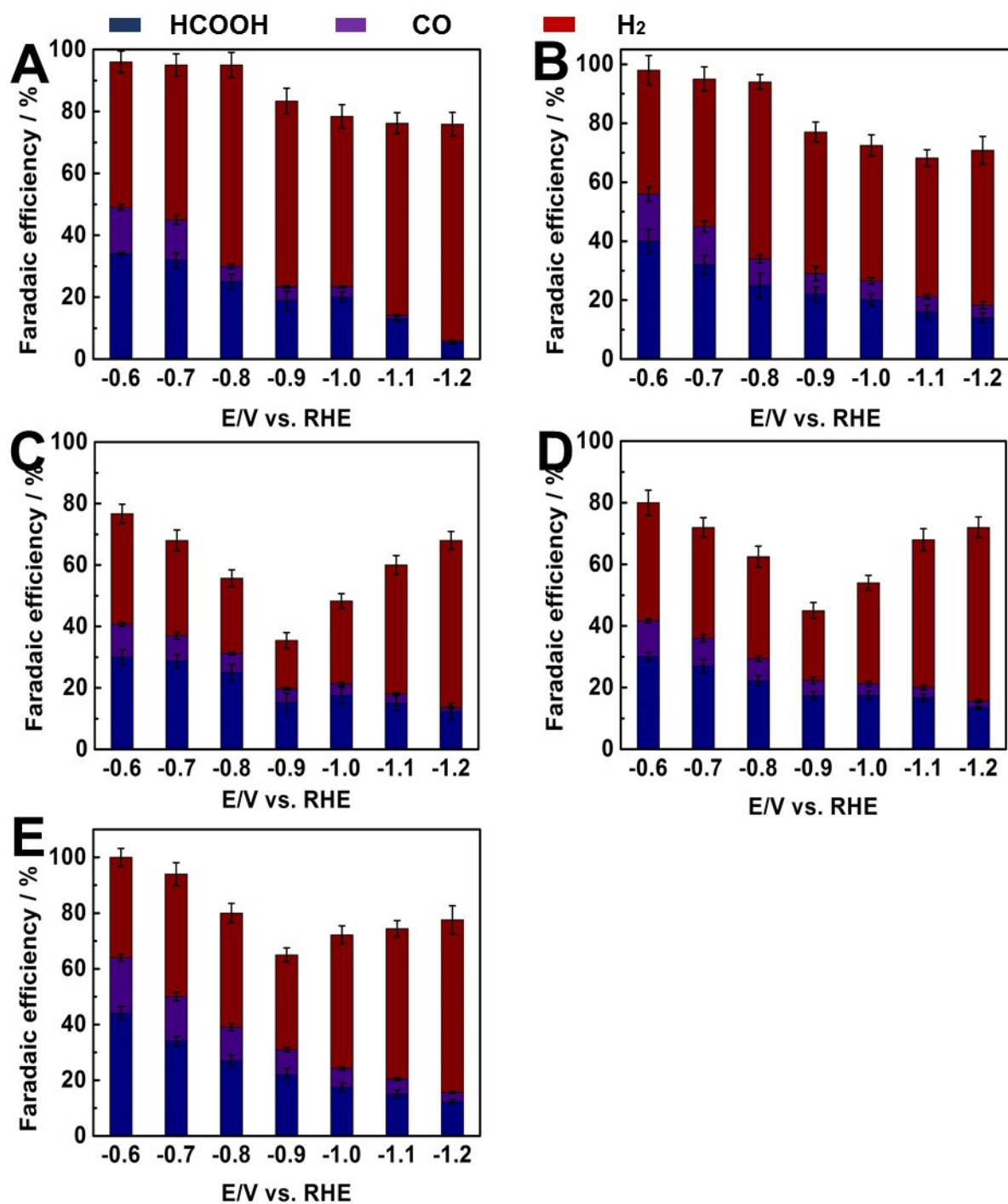


Figure S3. The distribution of H₂ and C1 products for R-Cu-x: R-Cu(OH)₂ (A), R-Cu-2 (B), R-Cu-5 (C), R-Cu-10 (D) and R-Cu-20 (E).

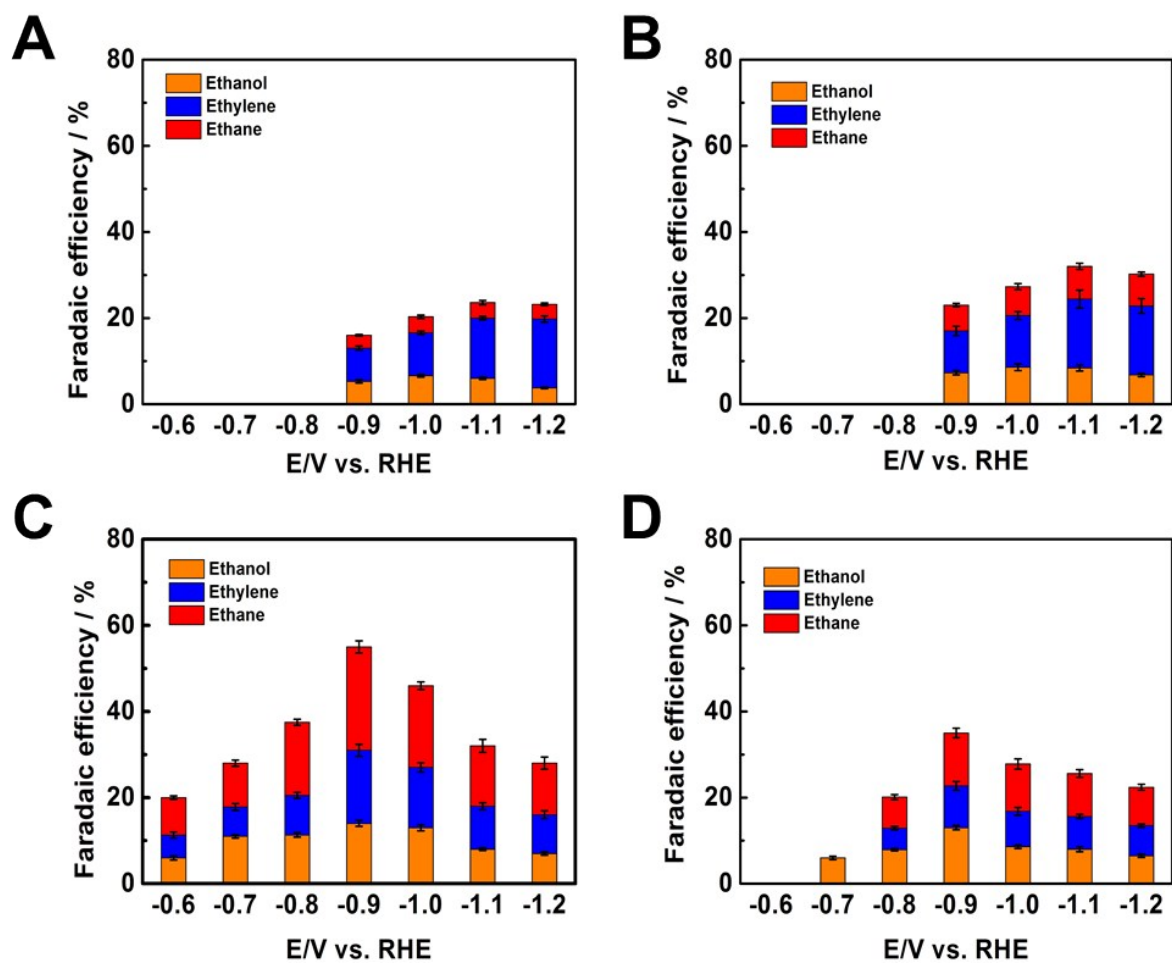


Figure S4. The distribution of C₂ products for R-Cu-x: R-Cu(OH)₂ (A), R-Cu-2 (B), R-Cu-10 (C) and R-Cu-20 (D).

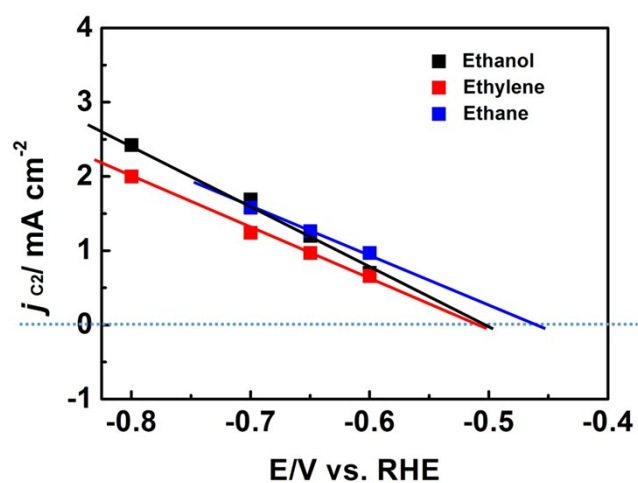


Figure S5. The onset potentials of C2 products for R-Cu-5, obtained from the tangent line method.

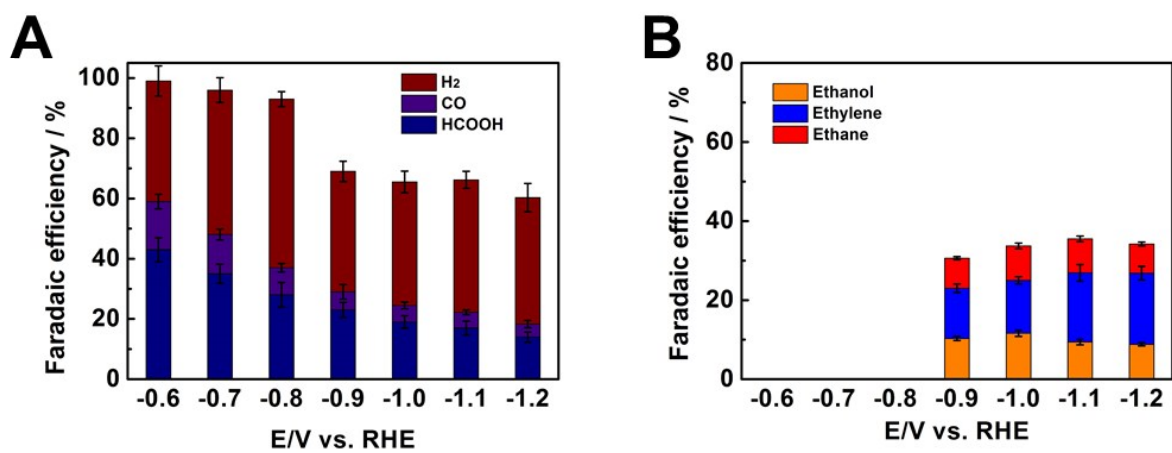


Figure S6. (A) The distribution of H₂ and C1 products for R-Cu-5 (400); (B) The distribution of C2 products for R-Cu-5 (400). R-Cu-5 (400) represents the material calcined at 400 °C for 5 min.

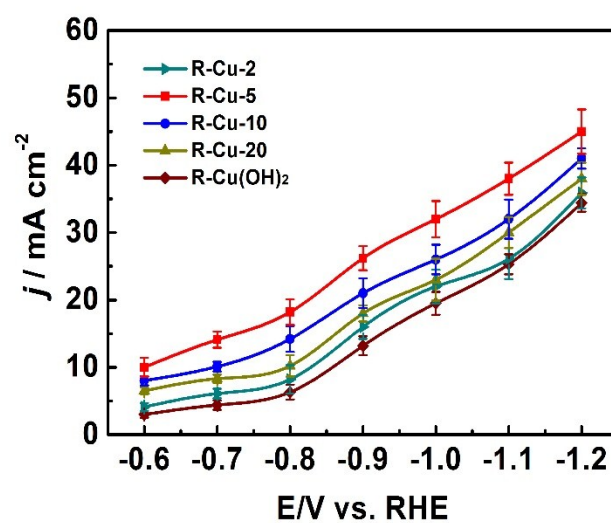


Figure S7. The total current density over different R-Cu-x.

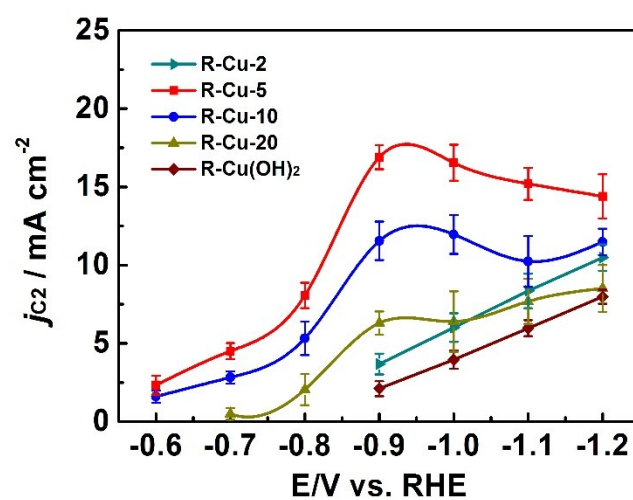


Figure S8. The current density for C2 products over different R-Cu-x.

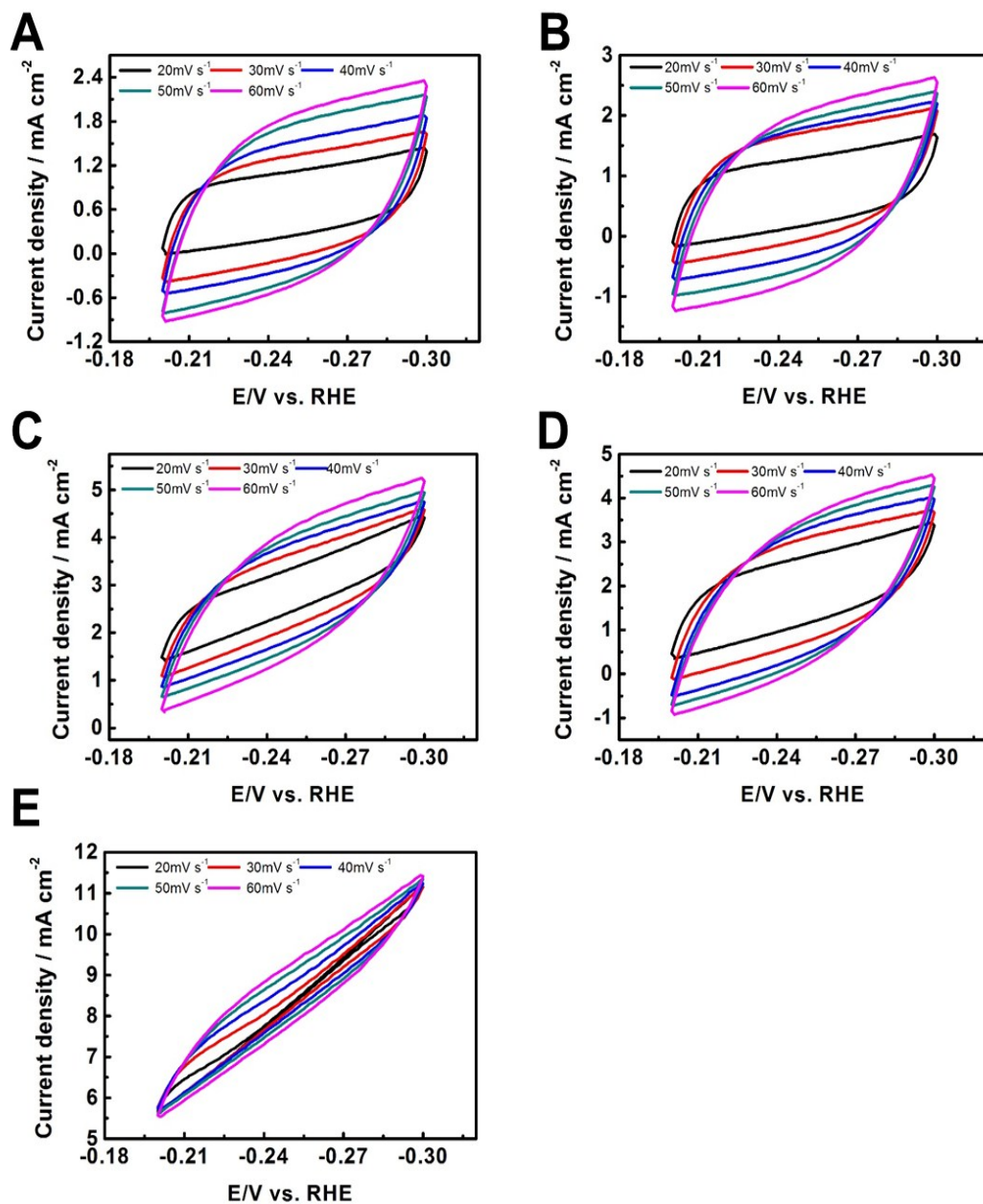


Figure S9. The cyclic voltammetry results on R-Cu-x at different scan rates: R-Cu(OH)₂ (A), R-Cu-2 (B), R-Cu-5 (C), R-Cu-10 (D) and R-Cu-20 (E).

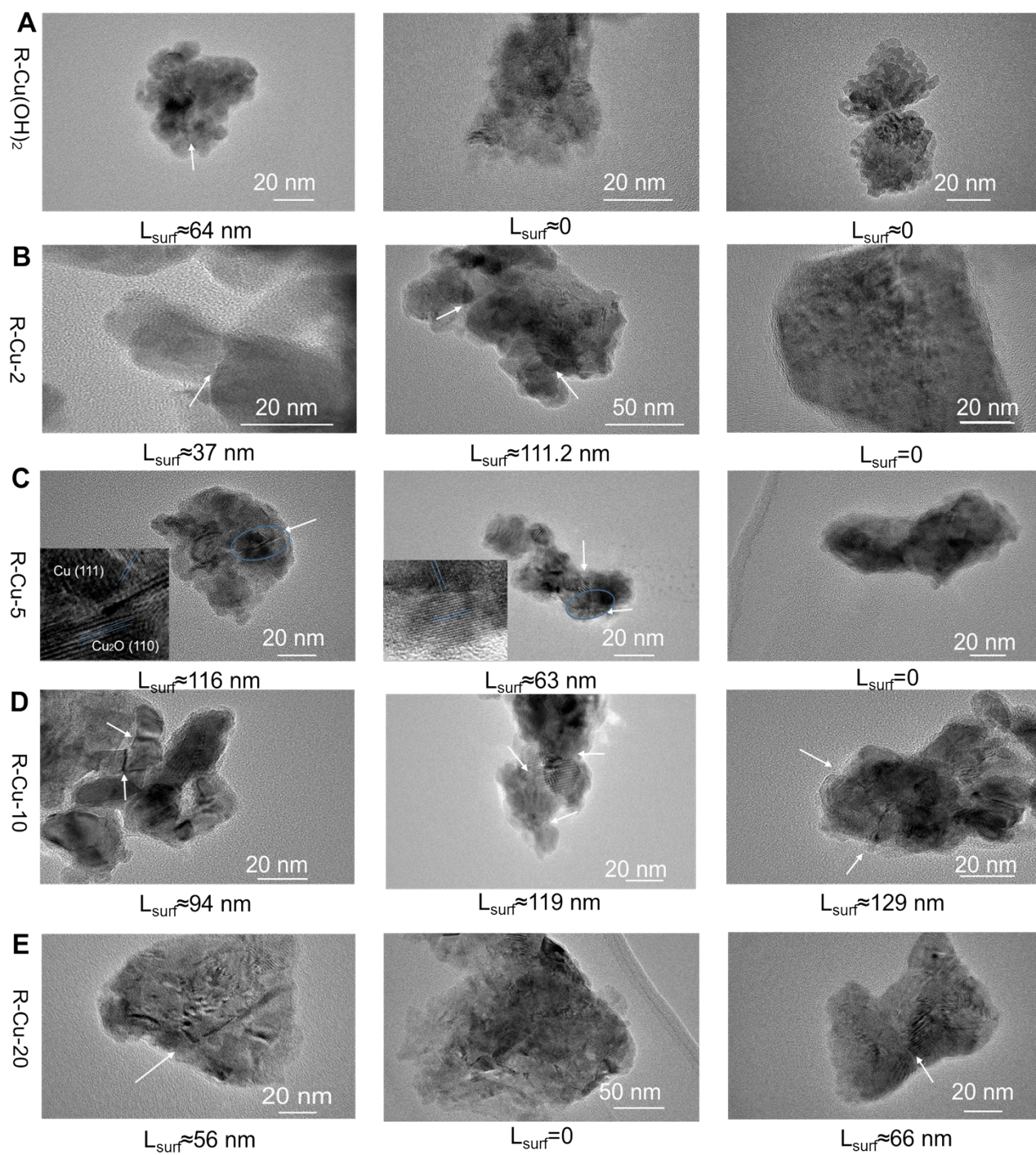


Figure S10. HR-TEM images of different R-Cu-x.

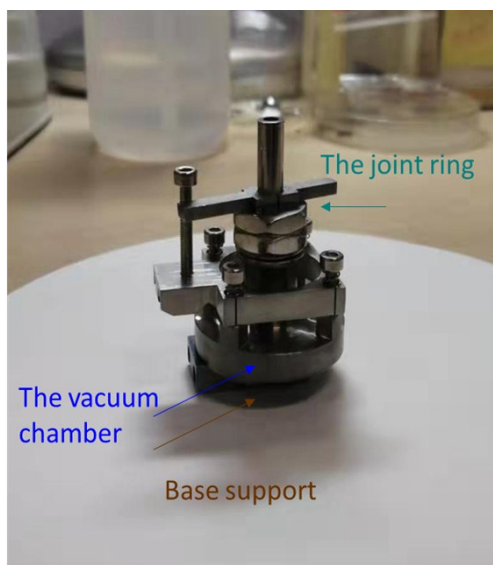


Figure S11. The optical pictures of the semi-in-situ XPS cell. The obtained electrode plate was cut into 3×3 mm and glued on the support. The vacuum chamber could be evacuated into vacuum to prevent the samples to be oxidized by the air.

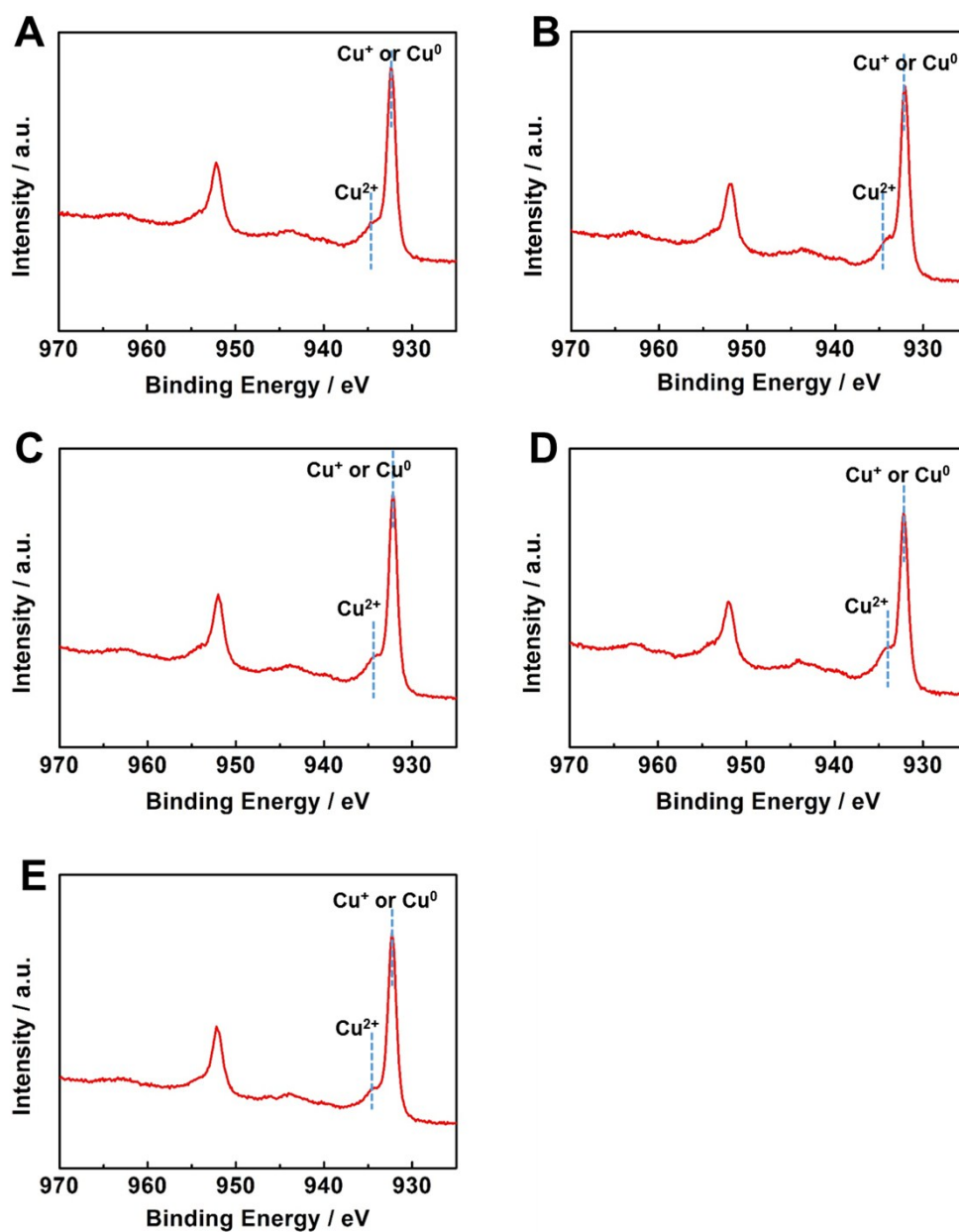


Figure S12. XPS spectra of Cu 2p orbits: R-Cu(OH)₂ (A), R-Cu-2 (B), R-Cu-5 (C), R-Cu-10 (D) and R-Cu-20 (E).

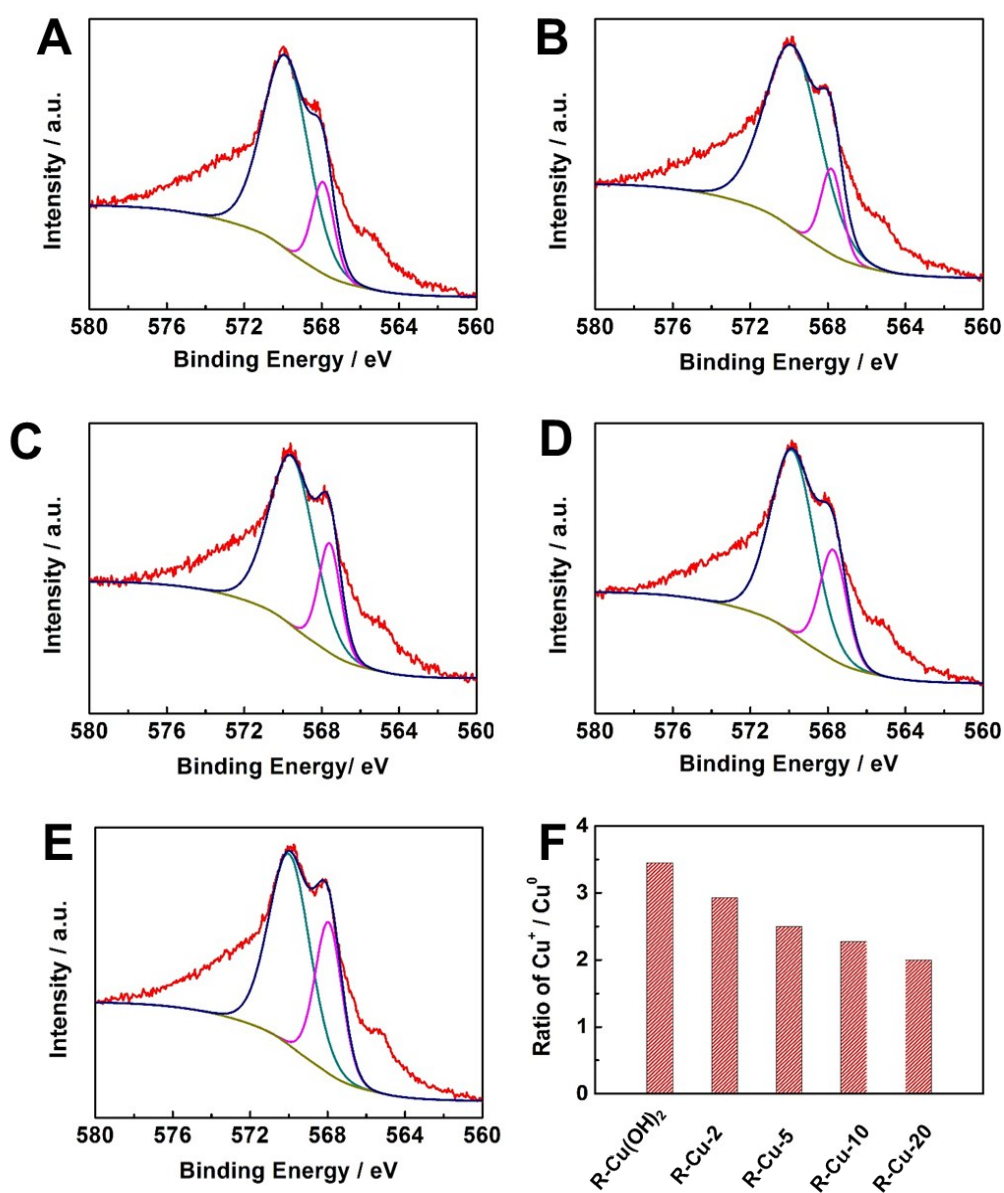


Figure S13. The fitting Auger Cu LMM line spectra: R-Cu(OH)₂ (A), R-Cu-2 (B), R-Cu-5 (C), R-Cu-10 (D), R-Cu-20 (E) and the ratios of Cu⁺/Cu⁰ over different R-Cu-x (F).

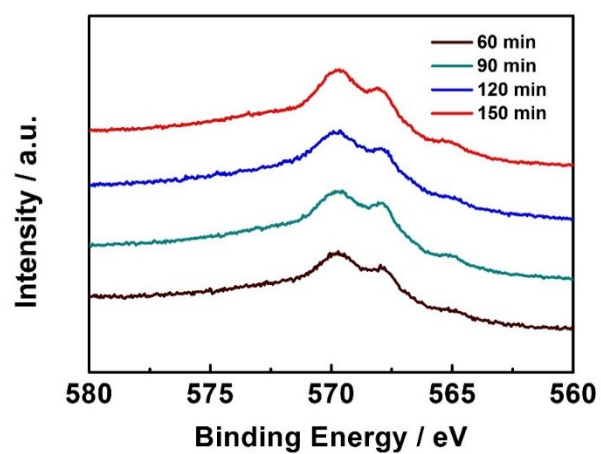


Figure S14. LMM Auger spectra of Cu for R-Cu-5 with different electrolysis time.

Supplementary Tables

Table S1. The onset potential of C2 products over R-Cu-x catalysts.

Catalysts	Ethane(V vs. RHE)	ethanol(V vs. RHE)	ethylene(V vs. RHE)
R-Cu(OH) ₂	-0.79	-0.78	-0.82
R-Cu-2	-0.73	-0.74	-0.76
R-Cu-5	-0.45	-0.50	-0.51
R-Cu-10	-0.45	-0.51	-0.53
R-Cu-20	-0.72	-0.73	-0.74

Table S2. Comparison of Optimized C2+ products on various Cu-based catalysts.

Samples	Substrate	electrolyte	E vs. RHE	FEC2+ (%)	reference s
R-Cu-5	Cu plate	0.1M KHCO ₃	-0.9	64.5	This work
Cu ₂ O NP/C	Glassy carbon	0.1M KHCO ₃	-1.1	74.0	S4
copper from a sol-gel	Carbon paper	0.1M KHCO ₃	-1.2	52.9	S5
Cu ₂ O-derived Cu NPs	Cu plate	0.1M KHCO ₃	-1.1	33.5	S6
Cu ₂ O-derived Cu NPs	Cu disc	0.1M KHCO ₃	-1.0	48.1	S7
Cu ₂ O (Cl induced)	Cu disc	0.1M KCl	-1.8	55.1	S8
Cu ₂ O film (1.7μm)	Cu disc	0.1M KHCO ₃	-0.99	47.9	S9
Mesoporous Cu ₂ O	Cu foam on Cu wafer	0.5M NaHCO ₃	-0.8	55.0	S10
Mesocrystal Cu from CuCl film	Cu disc	0.1M KHCO ₃	-0.99	27.2	S11
Agglomerated nanocrystal	Cu Cu disc	0.1M KHCO ₃	-0.95	60.3	S12
Transformed ensemble	Cu NP Carbon paper	0.1M KHCO ₃	-0.85	55.2	S13
Cu nanocube (44nm)	Glassy carbon	0.1M KHCO ₃	-1.1	50.1	S14
Cu NPs (7nm)	Glassy carbon	0.1M NaHCO ₃	-1.15	5	S15
Plasma-Copper Nanocube	Cu film	0.1M KHCO ₃	-0.9	60	S16

Table S3. Comparison of C2+ products on various Cu-based catalysts at low potentials.

catalysts	Electrolyte	j (C2) / mA cm ⁻²	FE (C2) / %	Potential (V vs. RHE)	Reference
R-Cu-5	0.1M KHCO ₃	2.3	22.5	-0.6	This work
R-Cu-5	0.1M KHCO ₃	4.5	32.1	-0.7	This work
B-Oxide-derived copper	0.1M KHCO ₃	2.2	27	-0.7	S1
Nanopores-Copper	0.1M KHCO ₃	0	0	-0.7	S17
Oxide-Derived Cu _x Zn	0.1M KHCO ₃	0	0	-0.7	S18
Plasma-Copper Nanocube	0.1M KHCO ₃	0.39	13	-0.7	S11
Amino acid modified copper	0.1M KHCO ₃	0.1	3	-0.7	S19
Metal ion cycling of Cu foil	0.25M KHCO ₃	1	8	-0.7	S20
copper from a sol-gel	0.1M KHCO ₃	0.3	3	-0.7	S5
Bi-Phasic Cu ₂ O-Cu	0.1M KHCO ₃	0.1	5	-0.7	S21
Highly Dense Cu Nanowires	0.1M KHCO ₃	3	25	-0.7	S22
Mixed Copper States in Anodized Cu	0.1M KHCO ₃	-	3	-0.7	S23

Table S4. The results of C_{dl} and roughness factor for different samples.

Catalysts	The slope (mF cm ⁻²)	C_{dl} (mF cm ⁻²)	roughness factor
R-Cu(OH) ₂	34.4	17.2	1
R-Cu-2	36.8	18.4	1.07
R-Cu-5	47.0	23.5	1.37
R-Cu-10	41.7	20.9	1.21
R-Cu-20	37.5	18.8	1.09

Table S5. The Grain boundaries surface density for different samples.

catalysts	Grain boundaries surface density (μm ⁻¹)
R-Cu(OH) ₂	12.7
R-Cu-2	36.9
R-Cu-5	64.8
R-Cu-10	86.4
R-Cu-20	57.2

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